Supporting Information

for

Sb$_2$S$_3$ grown by ultrasonic spray pyrolysis and its application in a hybrid solar cell

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Additional experimental data
Figure S1: Top-view SEM images of Sb$_2$S$_3$ layers grown by ultrasonic-CSP using a) a solution with Sb/S source ratio of 1:3 and b) a solution with Sb/S source ratio of 1:2. Crystalline and amorphous parts are evident in image a. The single tetrahedral crystal in image b is composed of Sb and O according to EDX.
Figure S2: Top-view SEM image of Sb$_2$S$_3$ crystals grown by 7-cycles of spraying of solutions with Sb/S precursor ratio of 1:6 onto a TiO$_2$ substrate kept at 250 °C.
Figure S3: Optical transmittance of the glass/ITO/TiO$_2$/Sb$_2$S$_3$ stack at two different photon energies (1.9 eV and 2.5 eV) as a function of Sb$_2$S$_3$ growth cycles. The transmittance includes the specular and the diffuse component.
Figure S4: Current–voltage characteristics (A) and series resistance (B) of the glass/ITO/TiO$_2$/Sb$_2$S$_3$/P3HT/Au solar cells as a function of the duration of light-soaking using A.M1.5 illumination up to 45 min. The series resistance of the solar cell is calculated using the slope of the $I$–$V$ curve rightwards from the location of the $V_{oc}$. 